

GEMOLOGICAL INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

| May 24, 2024 | | | | |
|--------------------------------|--------------------------|--|--|--|
| IGI Report Number | LG635414650 | | | |
| Description | LABORATORY GROWN DIAMOND | | | |
| Shape and Cutting Style | EMERALD CUT | | | |
| Measurements | 9.61 X 6.36 X 4.15 MM | | | |
| GRADING RESULTS | | | | |
| Carat Weight | 2.62 CARATS | | | |
| Color Grade | D | | | |
| Clarity Grade | VVS 2 | | | |
| ADDITIONAL GRADING INFORMATION | | | | |

| Polish | EXCELLENT |
|----------------|-----------------|
| Symmetry | EXCELLENT |
| Fluorescence | NONE |
| Inscription(s) | 131 LG635414650 |

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa

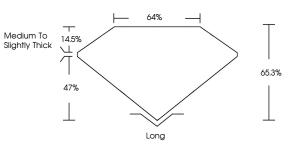
LG635414650 Report verification at igi.org

PROPORTIONS

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.



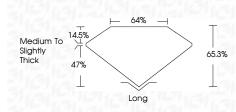
1691 LG635414650 Sample Image Used

COLOR

| D E F | GHIJ | Faint | Very Light | Light |
|------------------------|--------------------------------|---|----------------------|------------|
| CLARITY | | | | |
| IF | VVS ¹⁻² | VS ¹⁻² | SI ¹⁻² | 1-3 |
| Internally Flawless | Very Very Slightly Included | Very Slightly Included | Slightly Included | Included |
| © I | Gi 2020, International G | CILVER AND | | FD - 10 20 |
| | | | | |
| 6 | |) WITH THE FOLLOWING SECURITY MEASU AM AND OTHER SECURITY FEATURES NOT LIS | | |

May 24, 2024

| IGI Report Number | LG635414650 |
|-------------------|--------------------------|
| Description | LABORATORY GROWN DIAMOND |
| Shape and Cutting | Style EMERALD CUT |
| Measurements | 9.61 X 6.36 X 4.15 MM |
| GRADING RESULTS | 5 |
| Carat Weight | 2.62 CARATS |
| Color Grade | D |
| Clarity Grade | VVS 2 |
| | |



ADDITIONAL GRADING INFORMATION

| Polish | EXCELLENT |
|---|---------------------------|
| Symmetry | EXCELLENT |
| Fluorescence | NONE |
| Inscription(s) | (G) LG635414650 |
| Comments: This Laboratory (created by Chemical Vapo process and may include po Type IIa | r Deposition (CVD) growth |





